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CONTINUING DATA

This application is a CON of 09/985,322 M/02/2001

FOREIGN APPLICATIONS **

JAPAN 378040/2000 12/12/2000 JAPAN 388385/2000 12/21/2000 JAPAN 3666/2001 01/11/2001 JAPAN 5128/2001 01/12/2001 JAPAN 17901/2001 01/26/2001 JAPAN 21183/2001 01/30/2001 JAPAN 23804/2001 01/31/2001 JAPAN 26580/2001 02/02/2001 JAPAN 31901/2001 02/08/2001 JAPAN 31906/2001 02/08/2001 JAPAN 33599/2001 02/09/2001 JAPAN 44964/2001 02/21/2001 JAPAN 52095/2001 02/27/2001 JAPAN 73380/2001 03/15/2001 JAPAN 131238/2001 04/27/2001 JAPAN 158571/2001 05/28/2001

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ADDRESS 38834 WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP 1250 CONNECTICUT AVENUE, NW SUITE 700 WASHINGTON, DC 20036 TITLE Eiectron beam apparatus and method of manufacturing semiconductor device using the apparatus									
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